

Santamauro, Jon

From: CCIRIOS@aol.com
Sent: Thursday, April 26, 2001 6:04 PM
To: scpcomments@uspto.gov
Subject: International Harmonization of patent laws

Dear Mr. John P. Santamauro,

After review the documentation posted on the USPTO.Gov website, I am greatly concerned over the proposed International Harmonization of patent laws being proposed. As an independent inventor I feel these measures would have adverse effects on my efforts to be a successful independent inventor. As you are well aware, the current process to apply for a patent is not only lengthy but also a real challenge even for the most committed. Financially, many independent inventors will have great difficulty competing with larger institutions or foreign entities if these new proposals were to take effect.

We are a proud nation with many embedded ideals, which include the idea; anyone can create, invent and succeed with initiative and commitment. Please reconsider approval of the proposed changes. The impact to fellow inventors will be devastating.

Sincerely,

Rick Rios

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